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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/603,351	06/25/2003	Wen Chin Lin	N1085-00147	2589
8933 75	590 11/05/2004		EXAMINER	
DUANE MORRIS, LLP			TSAI, H JEY	
IP DEPARTMENT ONE LIBERTY PLACE			ART UNIT	PAPER NUMBER
PHILADELPHIA, PA 19103-7396			2812	

Please find below and/or attached an Office communication concerning this application or proceeding.

				1hr			
		Application No.	Applicant(s)				
Office Action Summary		10/603,351	LIN ET AL.				
		Examiner	Art Unit				
		H.Jey Tsai	2812				
Period fo	The MAILING DATE of this communication app or Reply	pears on the cover sheet with	the correspondence add	iress			
THE - External after - If the - If NC - Failu Any I	ORTENED STATUTORY PERIOD FOR REPL' MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period or tre to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply y within the statutory minimum of thirty (3 will apply and will expire SIX (6) MONTH\$, cause the application to become ABAN	y be timely filed 10) days will be considered timely. S from the mailing date of this cor DONED (35 U.S.C. § 133).				
Status							
1)🖂	Responsive to communication(s) filed on 12 Ju	<i>aly</i> 2004.					
2a)⊠	☐ This action is FINAL . 2b)☐ This action is non-final.						
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
	closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 1	1, 453 O.G. 213.				
Dispositi	ion of Claims						
4)⊠)⊠ Claim(s) <u>1-16</u> is/are pending in the application.						
	4a) Of the above claim(s) <u>12-16</u> is/are withdrawn from consideration.						
5)) Claim(s) is/are allowed.						
6)⊠	Claim(s) <u>1-11</u> is/are rejected.						
7)	Claim(s) is/are objected to.						
8)□	Claim(s) are subject to restriction and/o	r election requirement.					
Applicati	ion Papers						
9)	The specification is objected to by the Examine	r.					
10)	The drawing(s) filed on is/are: a) ☐ acc	epted or b) ☐ objected to by	the Examiner.				
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11)	The oath or declaration is objected to by the Ex	caminer. Note the attached O	ffice Action or form PT0	O-152.			
Priority ι	under 35 U.S.C. § 119						
12)	12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a)[a) All b) Some * c) None of:						
	1. Certified copies of the priority documents have been received.						
	2. Certified copies of the priority documents have been received in Application No						
	3. Copies of the certified copies of the priority documents have been received in this National Stage						
	application from the International Bureau	u (PCT Rule 17.2(a)).		_			
* 5	See the attached detailed Office action for a list	of the certified copies not rec	ceived.				
Attachmen	• •		_				
	ce of References Cited (PTO-892) te of Draftsperson's Patent Drawing Review (PTO-948)		nmary (PTO-413) Nail Date				
3) 🔲 Inform	nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08)		mal Patent Application (PTO	-152)			

This application contains claims 12-16 drawn to an invention nonelected claims.

A complete reply to the final rejection must include cancellation of nonelected claims or other appropriate action (37 CFR 1.144) See MPEP § 821.01.

Claim Rejections - 35 USC § 112

The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

Claims 1-11 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention. "Horizontal structure device" and "horizontal structure transistor" is not described in the specification.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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Claims 1-11 stand rejected under 35 U.S.C. 103(a) as being unpatentable over Cha 2002/0140016 in view of Background of the invention of same reference to Cha 2002/0140016.

The reference(s) teach the features:

Cha discloses a magnetic memory device using two conductive lines 137, 141 (para. 34) to control a combined magnetic field created thereof (para. 21), comprising:

forming a horizontal structure device/transistor includes layers

121/119/115/117/112 having substantially flat top surfaces, fig. 2A, Cha also teaches at fig.2A, a horizontal structure device includes a flat top surface layer 123, in figure 1, Cha teaches a horizontal transistor 35a/37a/33/37b/35b and a horizontal structure device with a planarized surface of layer 39,

a transistor device 113/115/117/119/121 formed on top of a substrate, fig. 2A, a magnetic tunnel junction device (MTJ, 100) connected to the transistor device through a straight-line connection line 125,

a first conductive line 137 over the MTJ 200 and connected with the MTJ 200, a second metal line 141 situated cross perpendicular to the first metal line 137, over the first metal line 137, and separated from the first metal line 137 by an insulation region 139 for jointly generating the combined magnetic field, para. 34.

The difference between the reference(s) and the claims are as follows: Cha teaches two conductive layers 137 and 141 perpendicular to each other in the body of the invention but does not teach that two conductive layer 137 and 141 are formed from

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metal. However, Cha teaches in the Background at para.12 and 15 of the same invention that two metal lines 47 and 61 are perpendicular to each other to jointly generate magnetic field for a MTJ device.

In addition, specific coating thickness of metal as claimed are taken to be obvious since these are variables of art recognized importance which are subject to routine experimentation and optimization and discovery of an optimum value for a known process is obvious. In re Aller, 105 USPQ 233 (CCPA 1955). And, even if applicants' modification results in great improvement and utility over the prior art, it may still not be patentable if the modification was within the capabilities of one skilled in the art, In Re Sola 25 USPQ 433.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to have modified Cha's conductive lines with metal lines as suggested by Cha's Background teaching because Cha teaches using two metal lines or conductive lines are perpendicular to each other to jointly generate magnetic field for a MTJ device.

Conclusions

Applicant's arguments filed July 12, 2004 have been fully considered but they are not persuasive. Applicant contends that instant invention teaches a horizontal structure in figs. 3a-3d. However, there is no teaching in the instant specification and figs. 3a-3a to support the "Horizontal structure device or transistor". In figure 3a-3e of the instant

invention, it merely teaches a collection of vertical structures 302, 304, 306, 308 with flat surface of layer 310. And, there is not seen "horizontal structure device or transistor" in the instant specification. Cha clearly teaches at figure 1, a horizontal transistor 35a/37a/33/37b/35b and a horizontal structure device with a planarized surface of layer 39. Cha also teaches at fig. 2A, a horizontal structure transistor/device includes layers 121/119/115/117/112 having substantially flat top surfaces. Cha also teaches at fig.2A, a horizontal structure device includes a flat top surface layer 123.

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry of a general nature or clerical matters or relating to the status of this application or proceeding should be directed to the customer service whose telephone number is (703) 308-4357 and Fax number (703) 872-9306.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to H. Jey Tsai whose telephone number is (571) 272-1684. The examiner can normally be reached on from 7:00 Am to 4:00 Pm., Monday thru Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Niebling can be reached on (571) 272-1679. The fax phone number for this Group is (703) 872-9306.

hjt

10/27/04

H. Jey Tsai

Primary Examiner

Patent Examining Group 2800